



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Customer Number: 20277

Kenji ITOGA, et al.

Confirmation Number: 5521

Application No.: 09/769,490

Group Art Unit: 2882

Filed: January 26, 2001

Examiner: C. Kao

For:

X-RAY EXPOSURE APPARATUS, X-RAY EXPOSURE METHOD, X-RAY MASK, X-RAY MIRROR, SYNCHROTRON RADIATION APPARATUS, SYNCHROTRON

RADIATION METHOD AND SEMICONDUCTOR DEVICE

AMENDMENT

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

The following Amendment and Remarks are submitted in response to the Office Action dated April 13, 2004.

08/13/2004 EABUBAK1 00000121 500417 09769490 01 FC:1201 344.00 DA